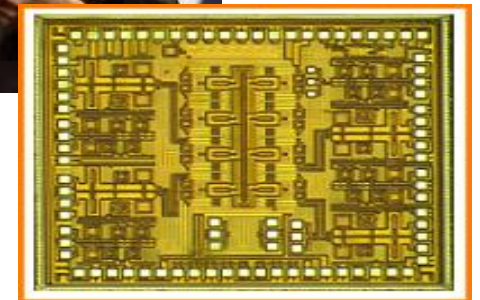
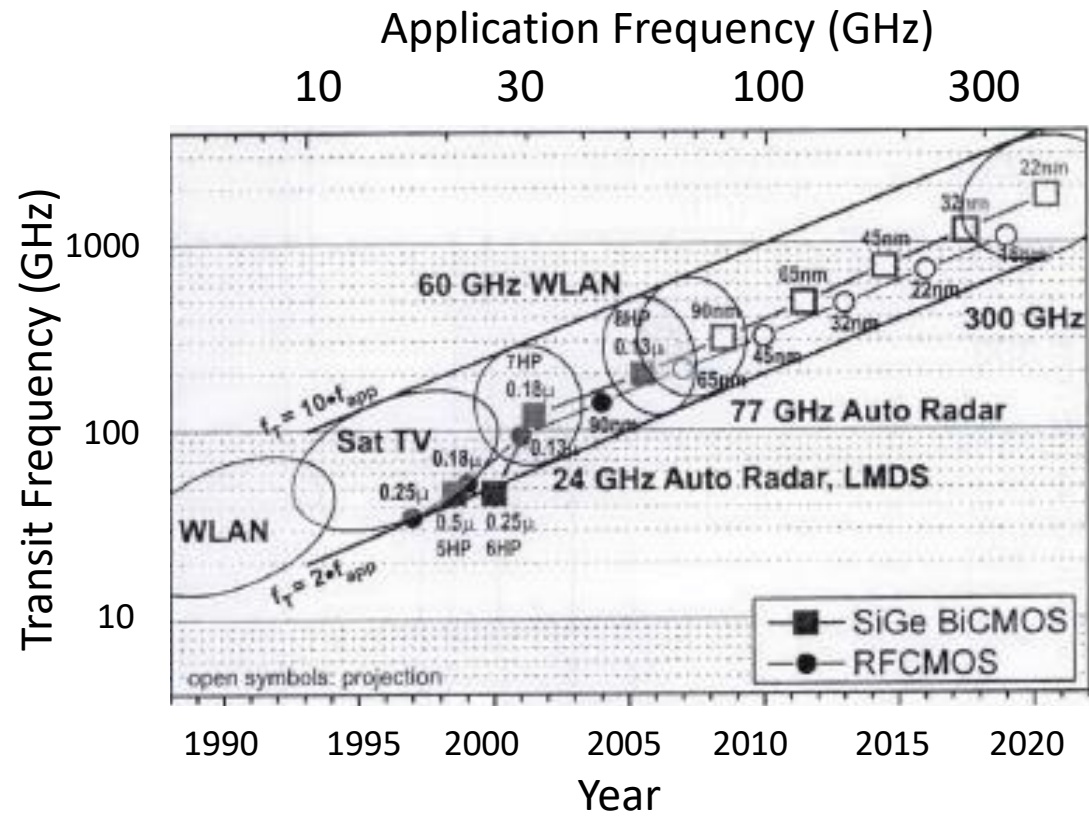


Future of Vector Network Analysis

Dylan Williams and Nate Orloff

Integrated Circuits Drive Wireless Communications

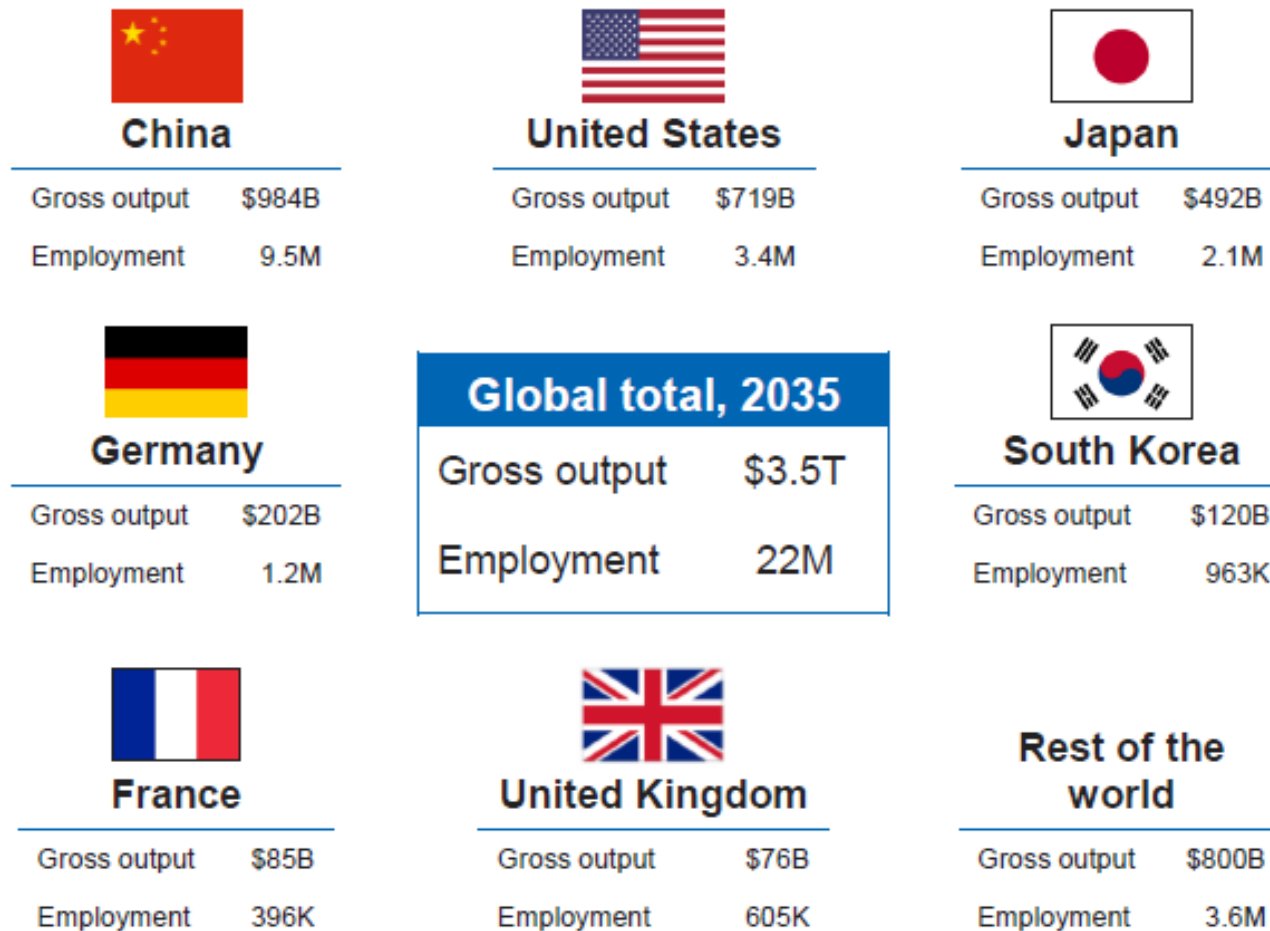


We Cannot Take the Integrated Circuit for Granted at mmWaves

Next 15 Years of Wireless Manufacturing by Country



The United States still dominates mmWave manufacturing

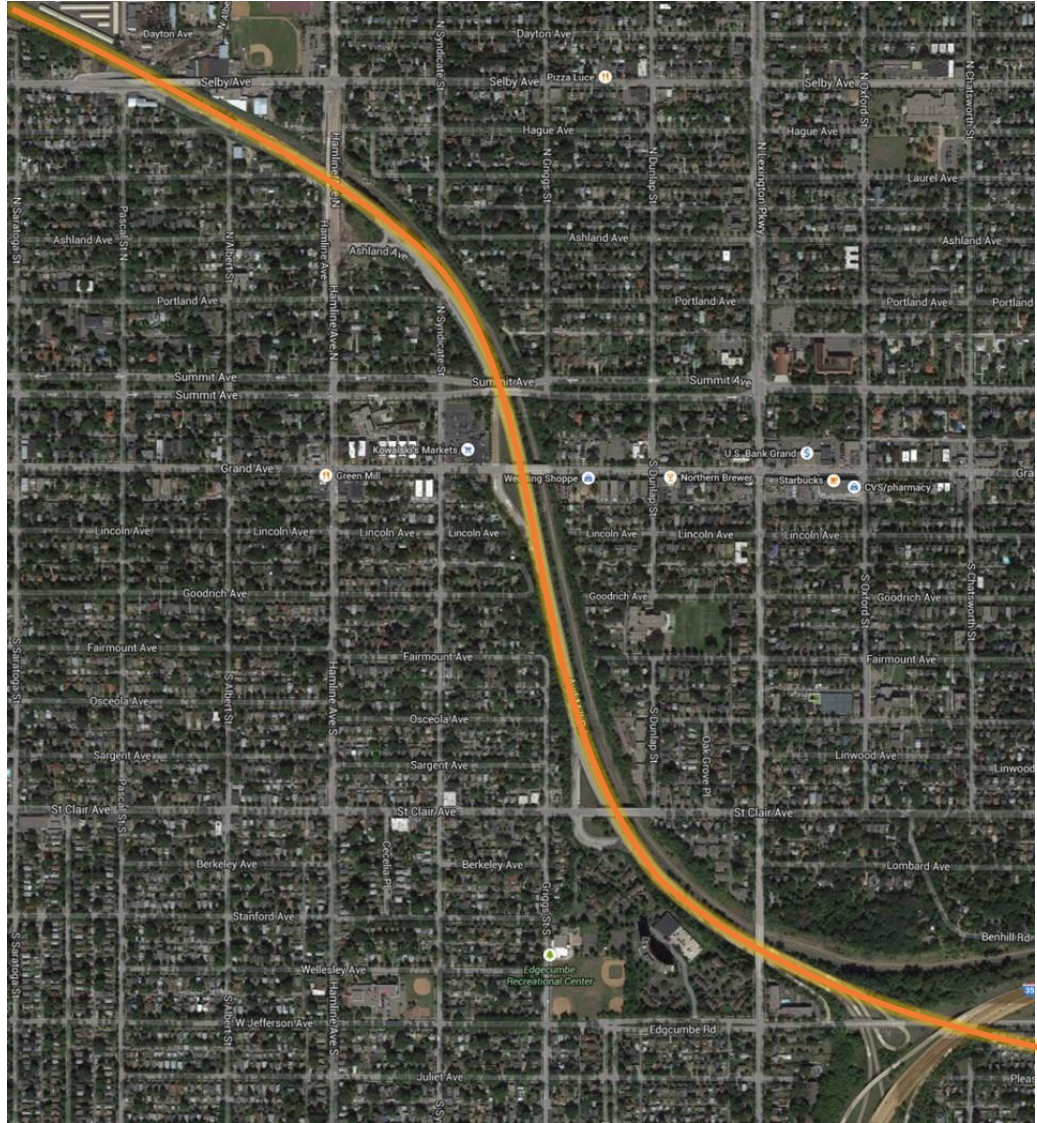


Notes: K = thousand, M = million, B = billion, T = trillion
Source: IHS

© 2017 IHS

Enables \$12.3T in Total Economic Growth (2020-2035)

Communication Providers Want Speed of Fiber on Your Phone



Federal Communications Commission FCC 19-30

Before the
Federal Communications Commission
Washington, D.C. 20554

In the Matter of)
Use of Spectrum Bands Above 24 GHz For) GN Docket No. 14-177
Mobile Radio Services)

FIFTH REPORT AND ORDER

Adopted: April 12, 2019

Released: April 15, 2019

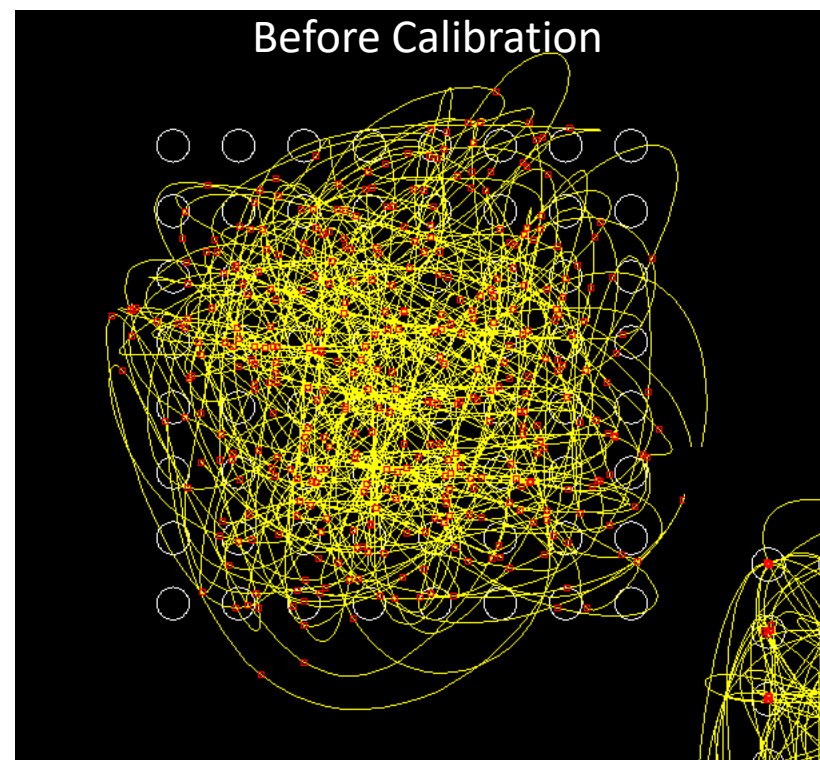
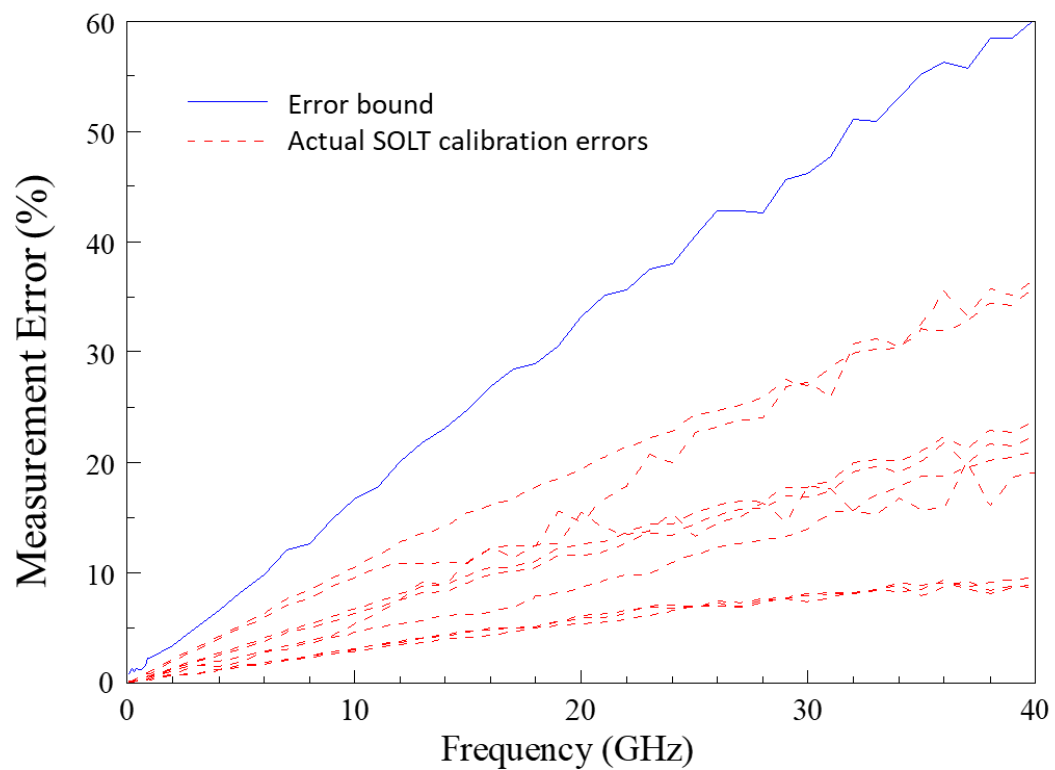
By the Commission: Chairman Pai and Commissioners O'Rielly and Carr issuing separate statements; Commissioners Rosenworcel and Starks approving in part, dissenting in part, and issuing separate statements.

I. INTRODUCTION

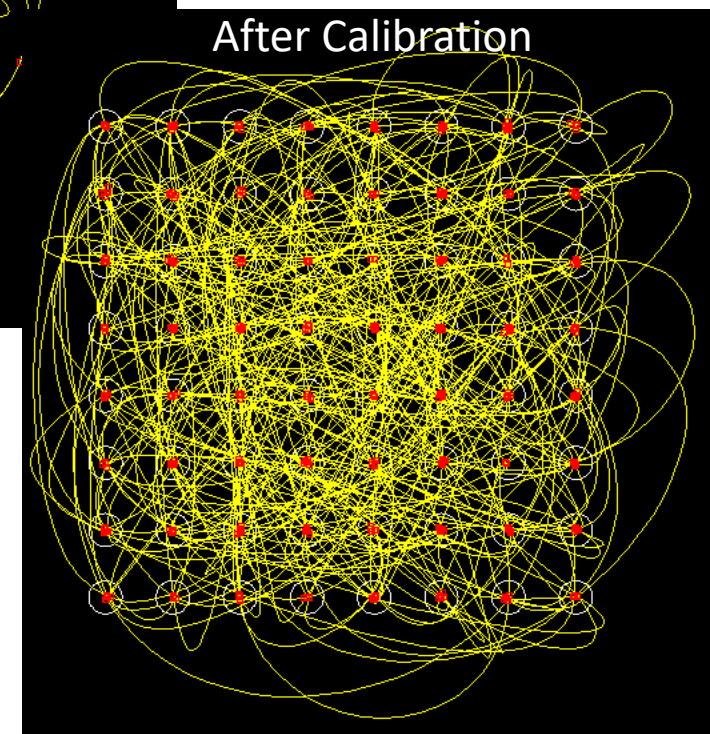
1. Today, we take two actions that continue our efforts to make available millimeter wave (mmW) spectrum, at or above 24 GHz, for fifth-generation (5G) wireless, Internet of Things, and other

Millimeter-Waves *are* the Next Wireless Frontier

Measurements and Calibrations Matter at mmWaves



64 QAM at 44 GHz



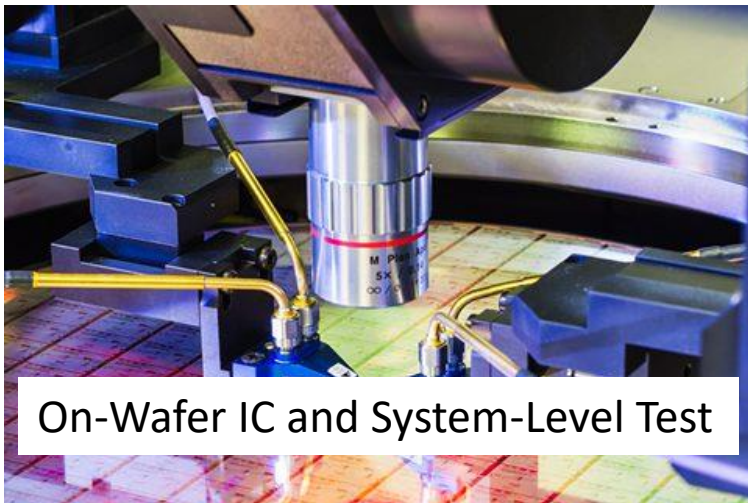
mmWave Measurement Challenge of our Era



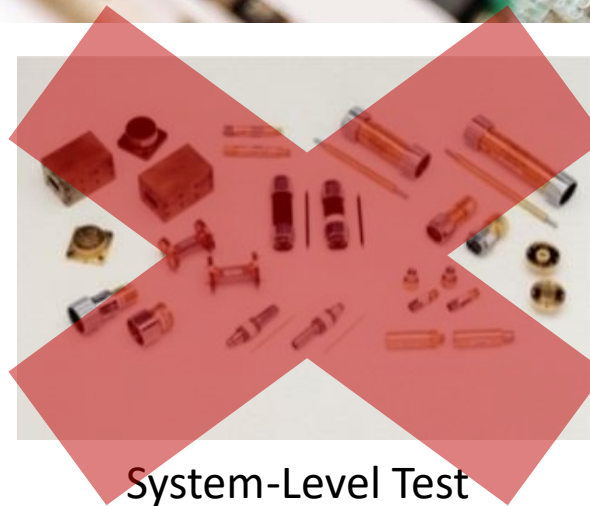
Not a Single RF Connector!



OTA System-Level Test



On-Wafer IC and System-Level Test



System-Level Test

Transistor models

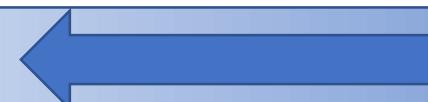
IC Test

End-to-End Verification

On-Wafer

Connectorized

Free-Space



Project Calibration Reference Planes On-Wafer and to OTA Test

On-Wafer Measurements

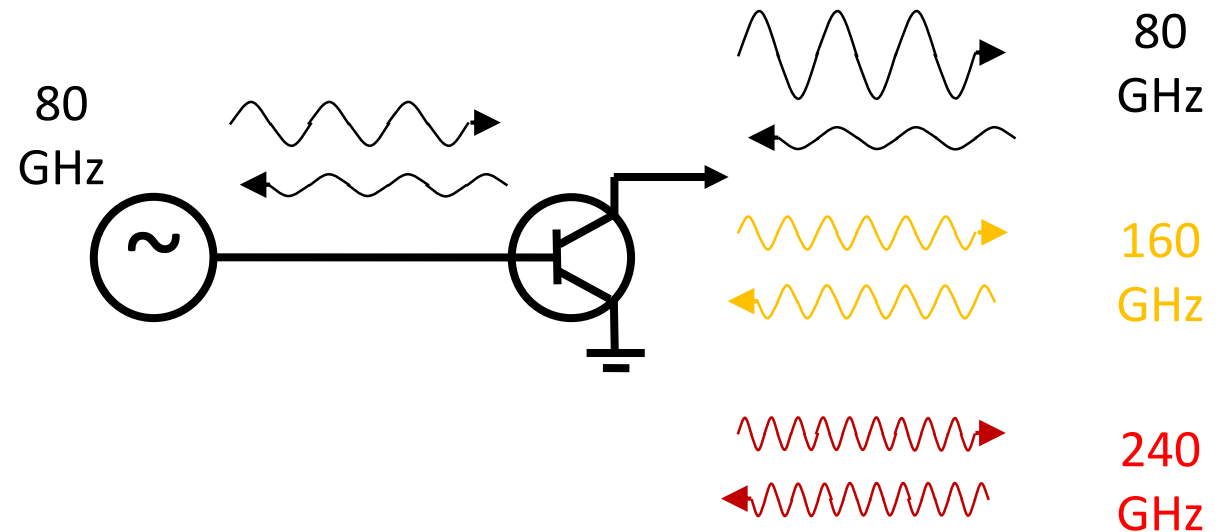
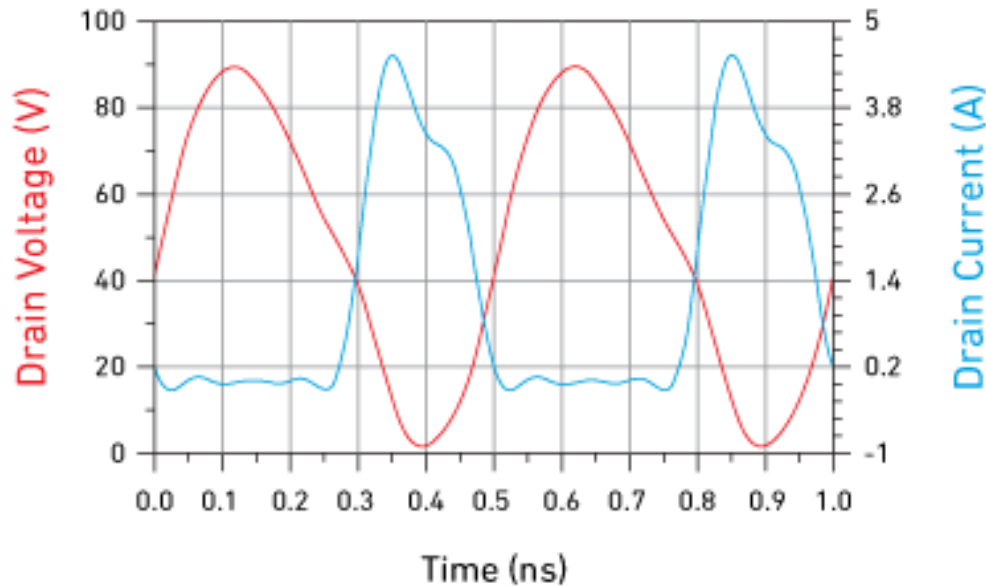
- Innovations in Calibration
- Support Device Models to System-Level Test
- State-Of-The-Art Instruments for US mmWave NR Manufacturers

Vector Network Analysis

- Platform for Traceable System-Level Tests Across CTL
- Close the Connector-Less Gap

mmWave Design Extremely Complex

Accurate measurements are a must



- Highly nonlinear operating states required for efficiency
- Characterize, capture, control and reuse harmonics
- Must maintain linearity

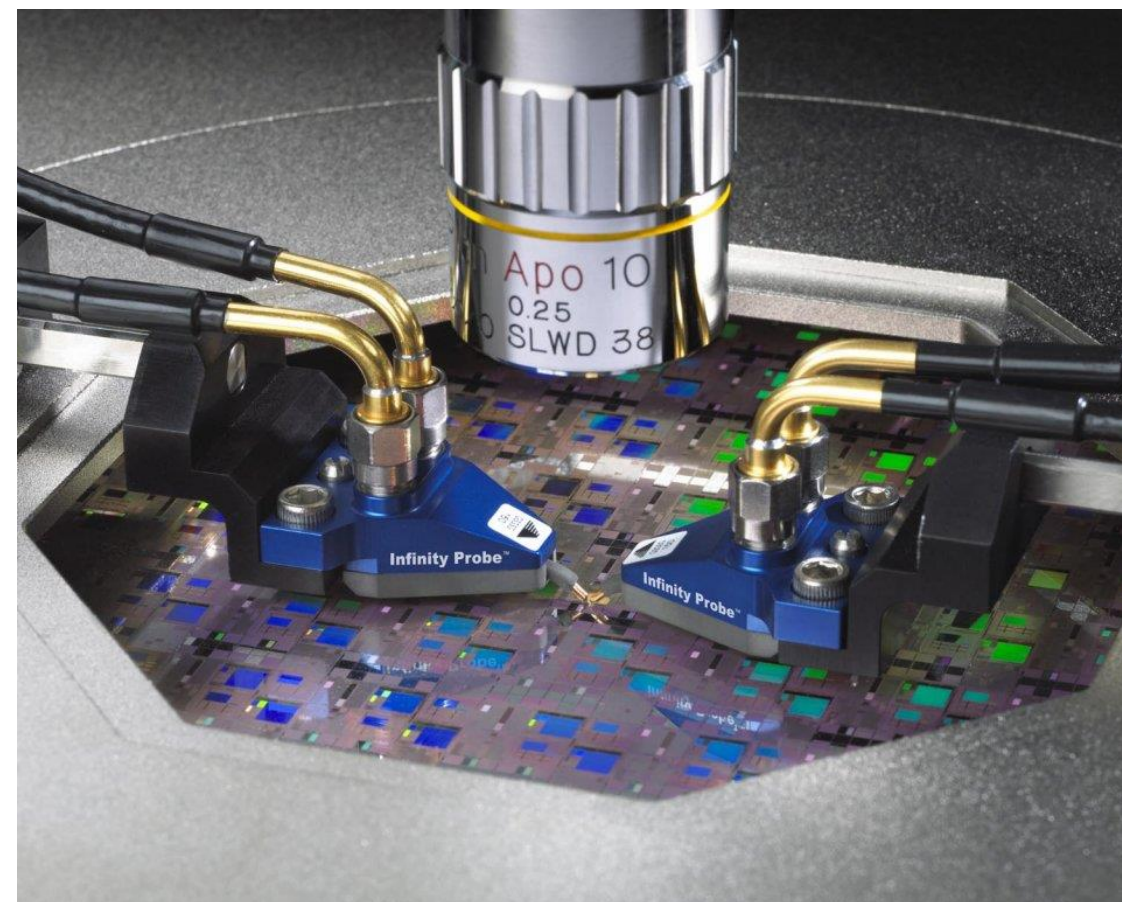
On-Wafer Measurement the Only Way to Test ICs

NIST

Yesterday

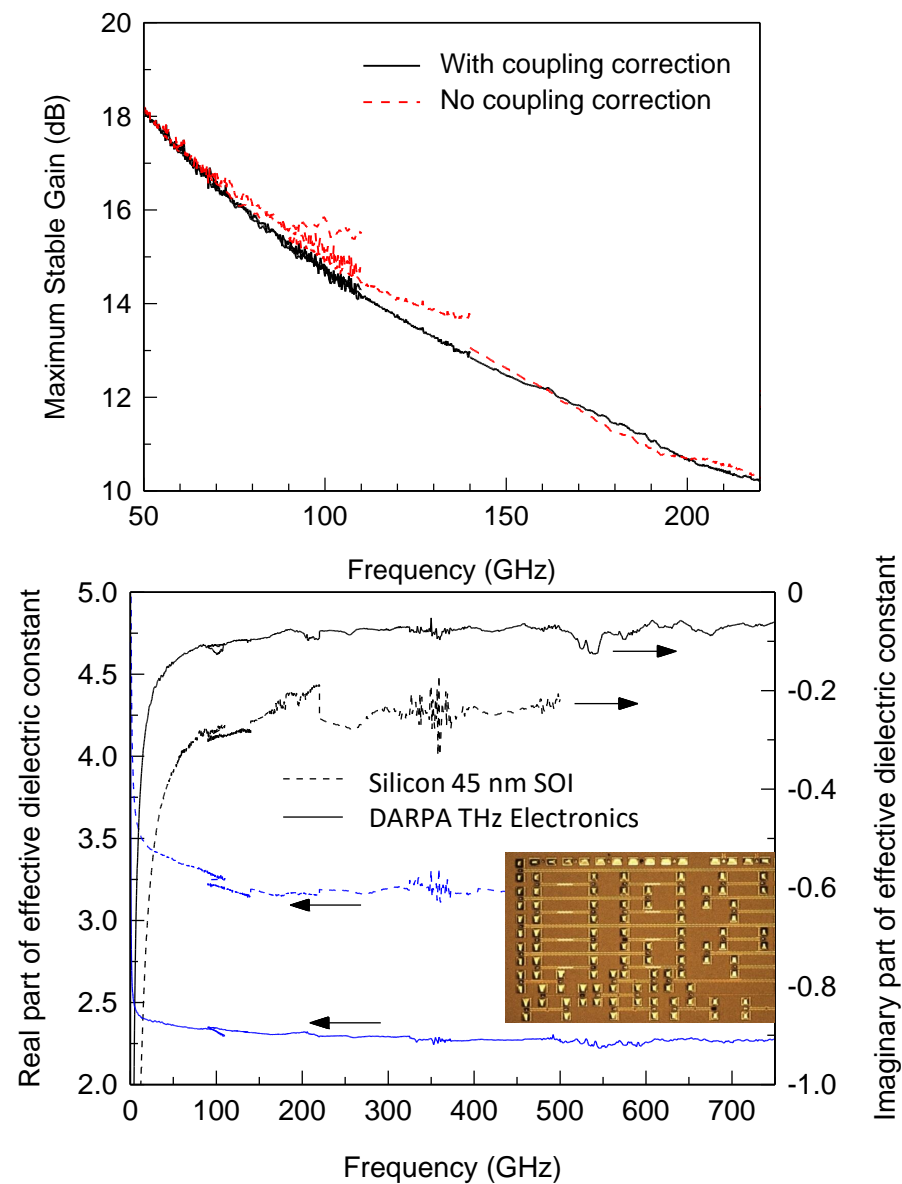
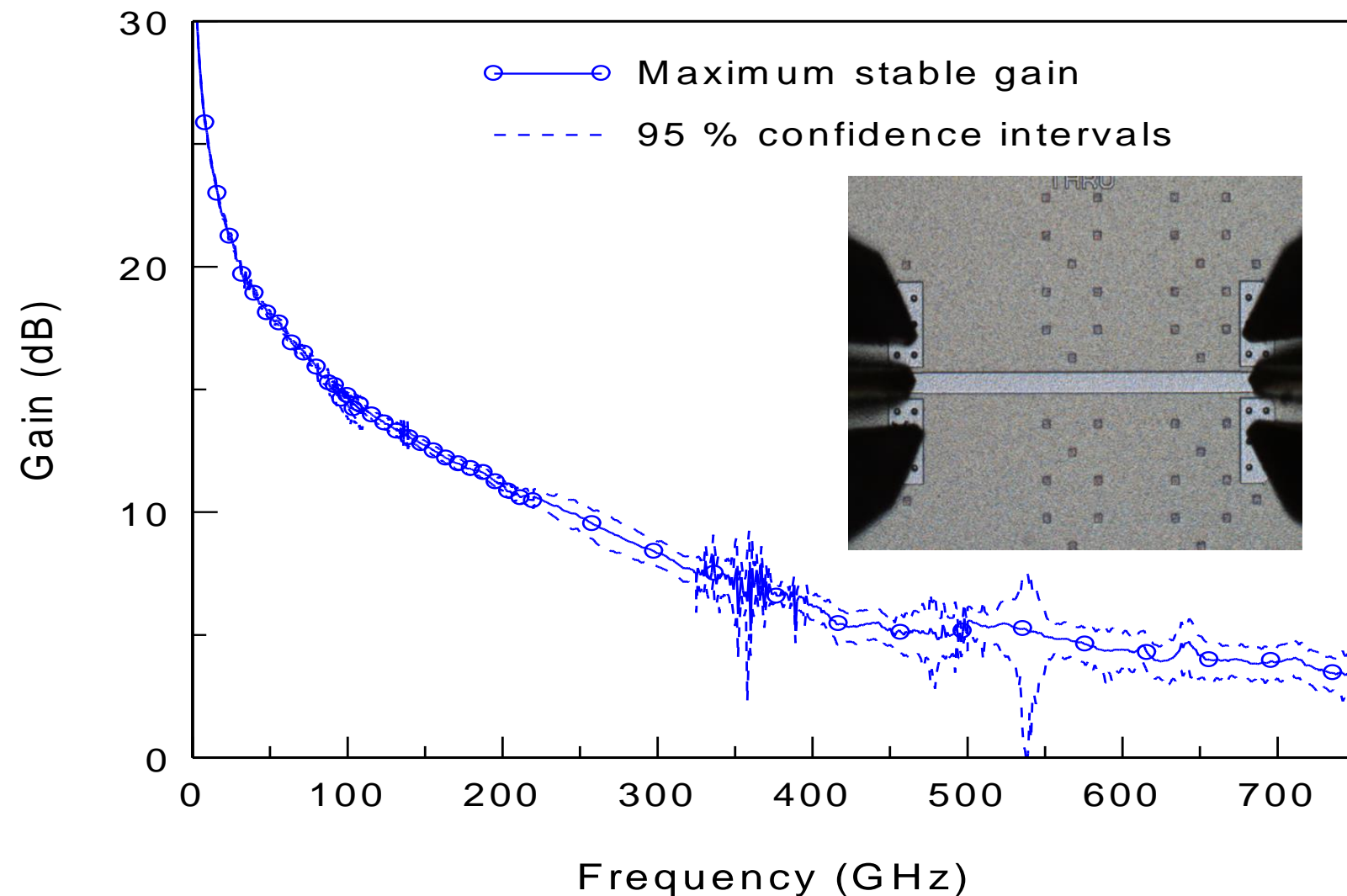


Today



CTL On-Wafer Accomplishments

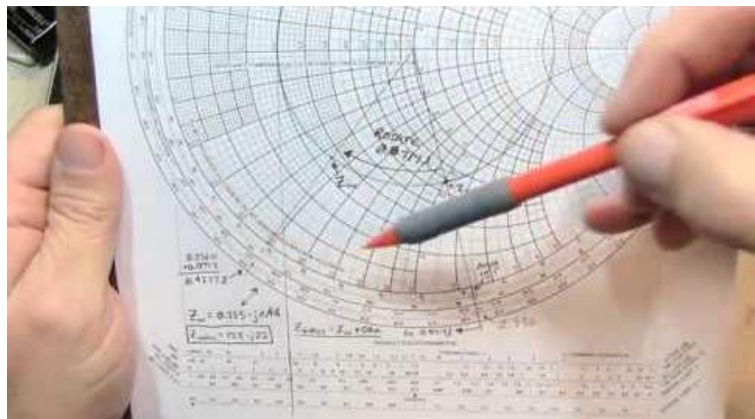
NIST On-Wafer Approaches Firmly Established as *the* Methods of Reference



Microwave Design Strategy Evolved Greatly

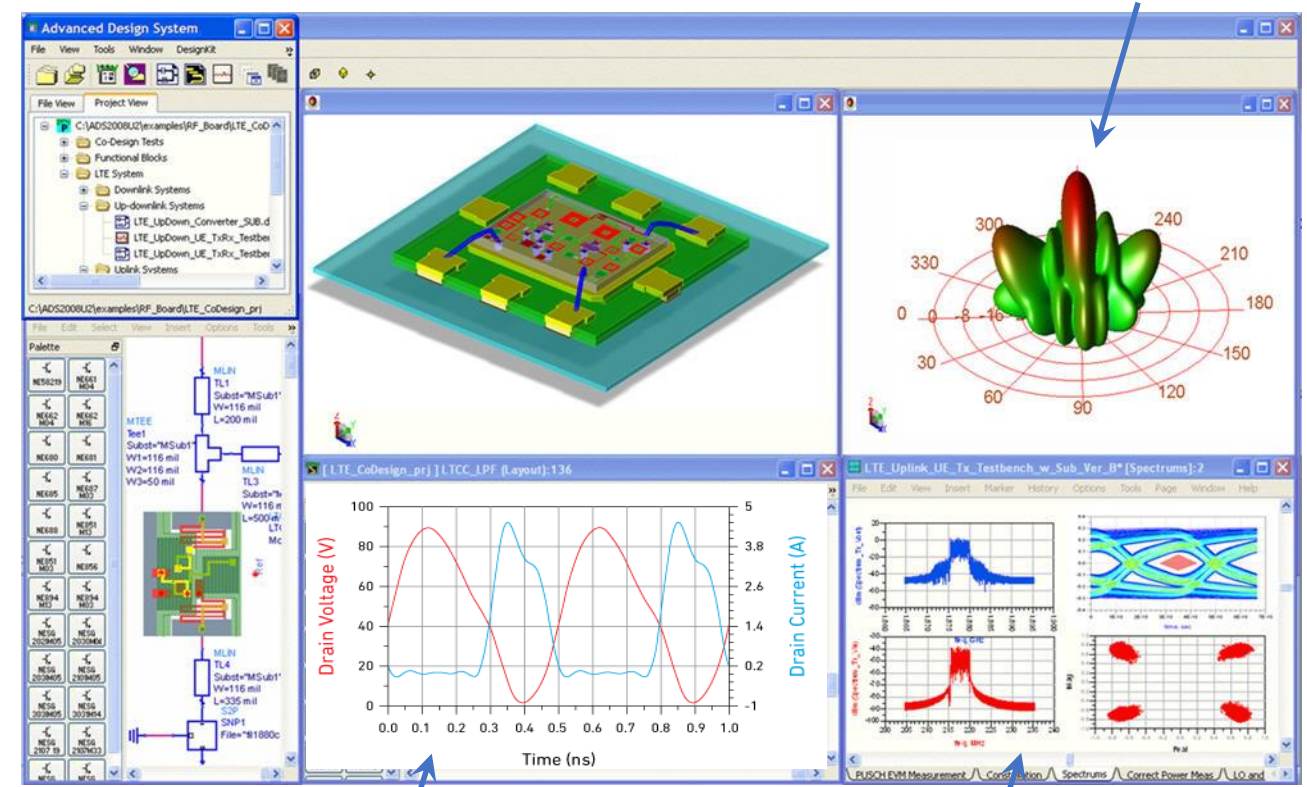


CTL Has Been Evolving Vector Network Analysis



Impedances, reflections and waves

50 Years Later



OTA system-level behavior

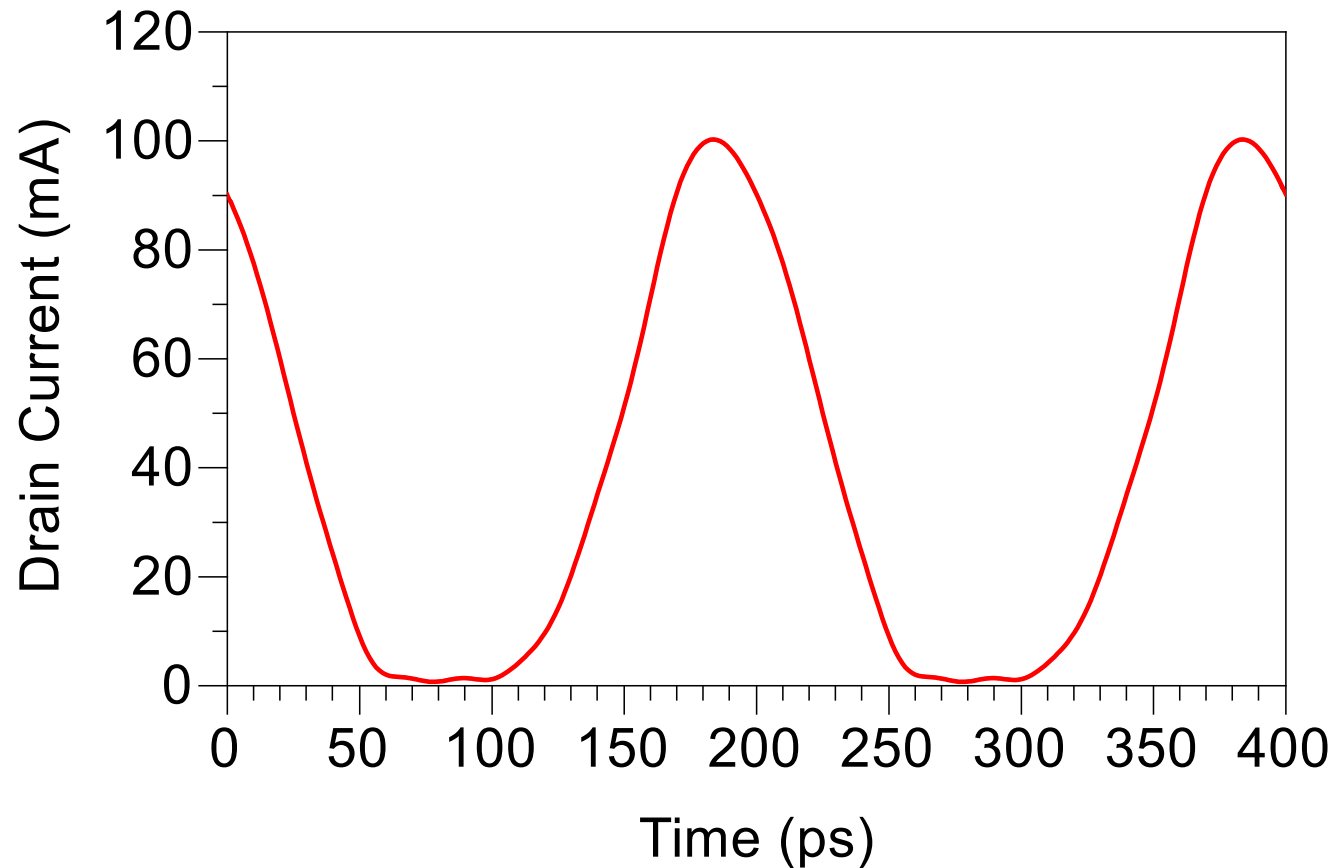
On-wafer voltages and currents

On-wafer system-level behavior

Vector Network Analysis Today

Same network analyzer

- S-parameter calibration
- **Add Power and Electrical-Phase calibration**



S-Parameter



Power



Phase

The Future of On-Wafer Vector Network Analysis

CTL Innovating in S-Parameters, Power and Electrical Phase

Scattering-Parameter Calibration Kit

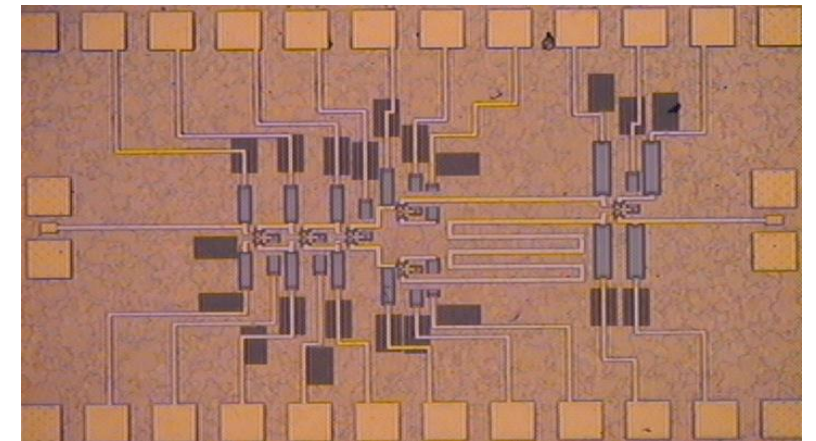
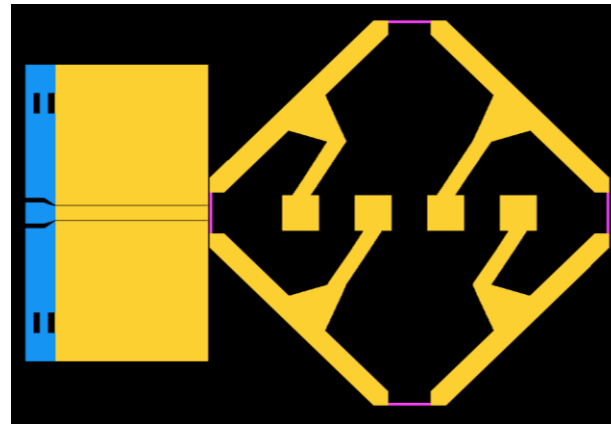
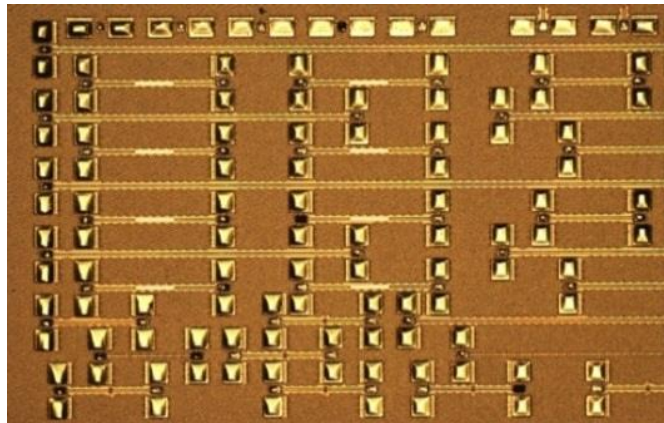
Power Meter

Electrical Phase Reference

Today

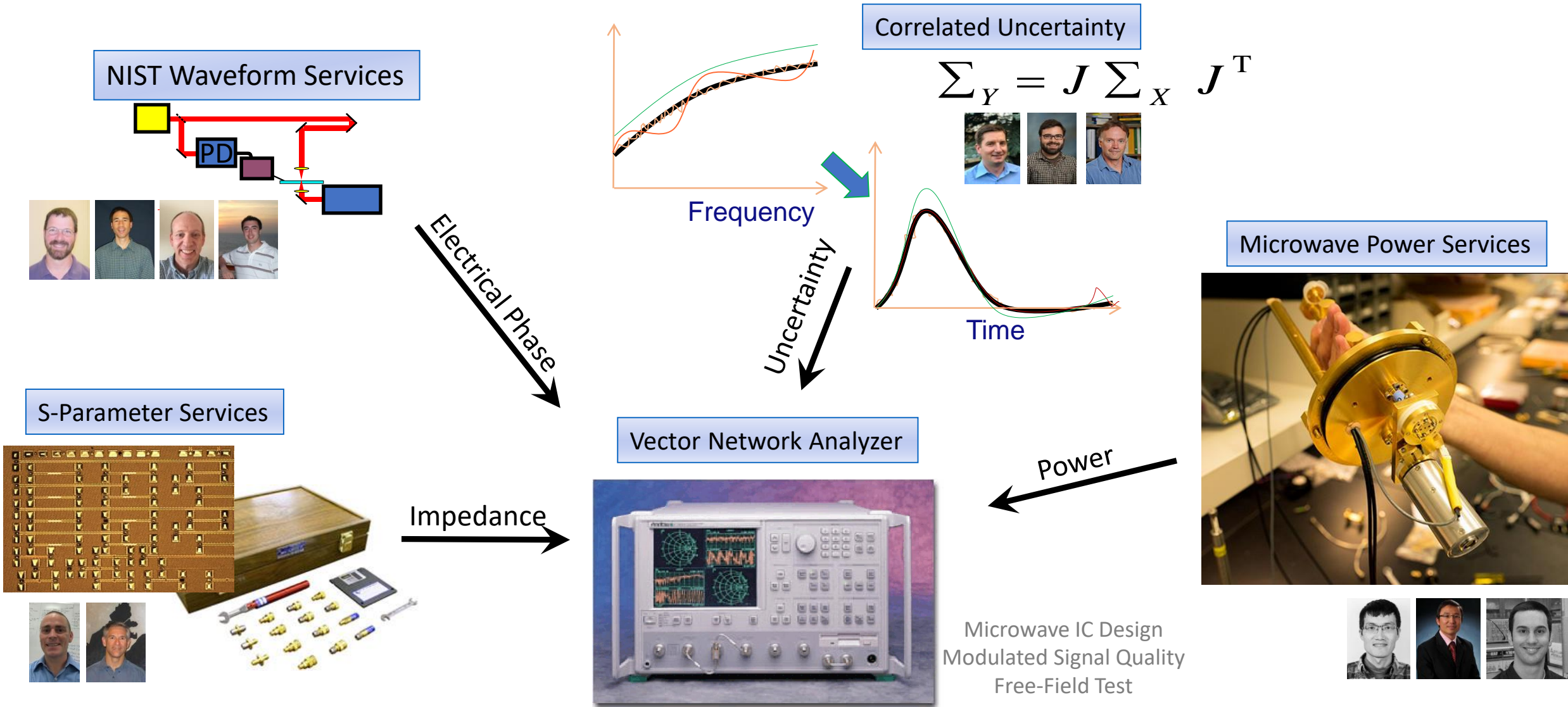


Tomorrow

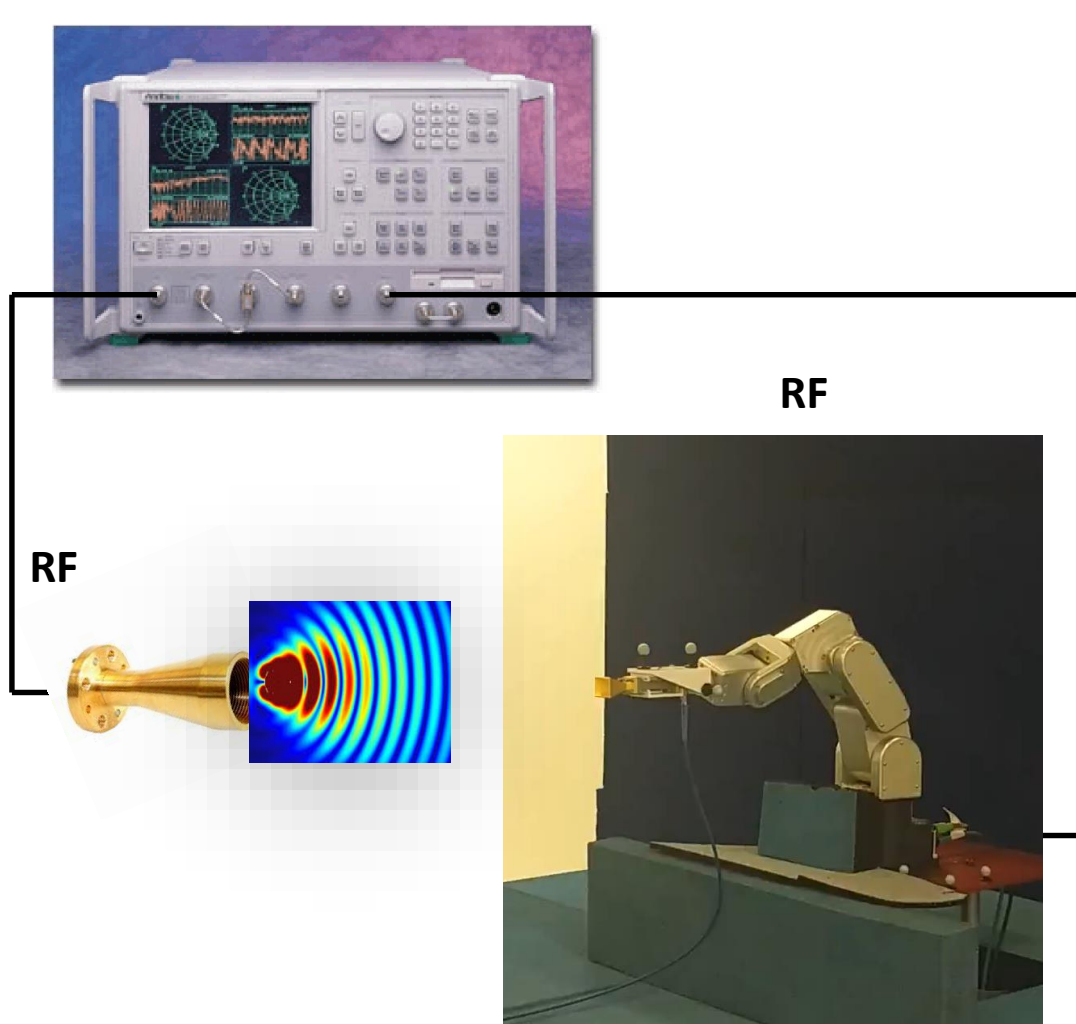


A Conduit for Traceability Inside and Outside CTL

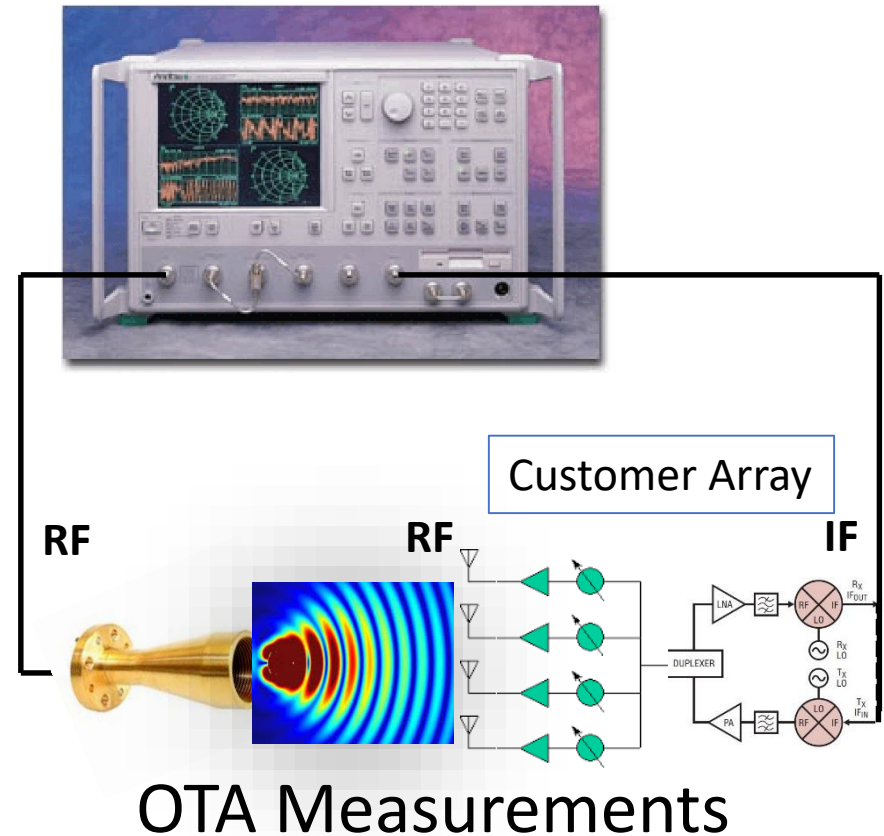
Vector Network Analysis Brings Power, Electrical Phase, Impedance and Waveforms to Remote Reference Planes



OTA System-Level Measurements



Characterize Fields



VNA Traceability For:

- Channel Distortion, AoA and Polarization
- Flexible RF-RF and RF-IF Measurements
- Multiple Traceable Modulated Signals

Some Outcomes of CTL Vector Network Analysis



On-Wafer Measurements

- On-Wafer Device-Modeling Capability with Uncertainty
 - GaN manufacturer asks for models with uncertainty
- On-Wafer Impedance-Power-Phase Calibration Kits
 - Power Standard with 100 GHz BW
 - Fabricated experimental on-wafer phase reference
- On-Wafer Instruments in a Probe
 - Self-calibrating, connector-less, 1 THz BW

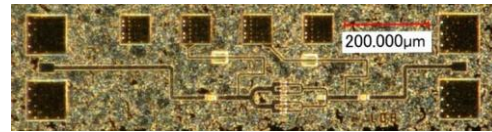
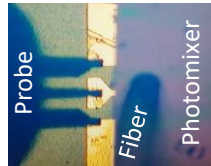
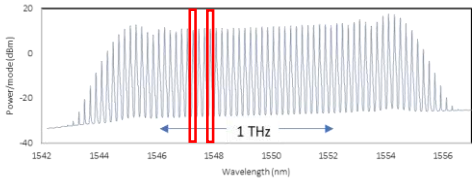
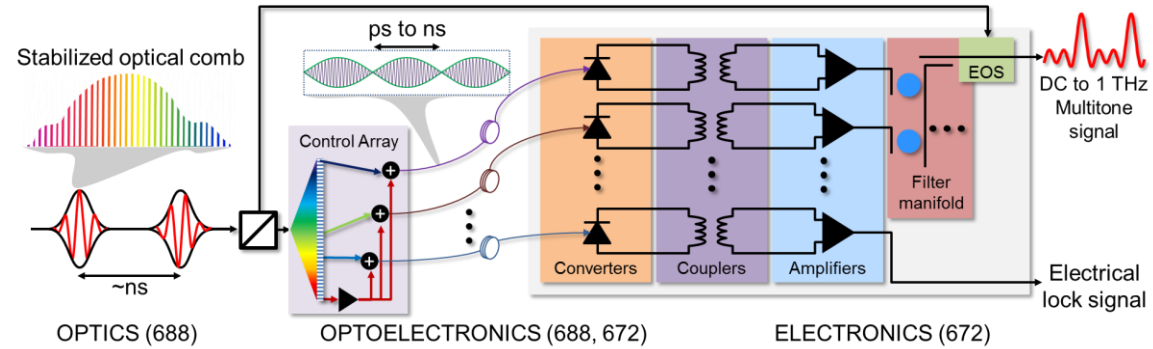
VNA Measurement Methods

- Improved VNA Synchronization for Accurate Modulated-Signal Measurement
 - Using similar technique Keysight announces accurate EVM measurements with VNA
- Traceable Characterization of any Signal AWG can Generate
 - Arbitrary frequency grid, dramatically improved sync/SNR
- Investing in Calibration Services
 - 4 New Staff Members
 - Waveform calibrations report both conventional and correlated uncertainties
 - Power and Scattering-Parameter Services migrating toward VNA transfers and correlated uncertainties

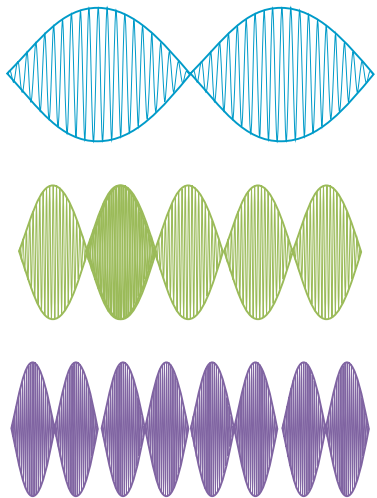
Impact on Instrument Makers

- Keysight adopts calibrated NIST Photodiodes for oscilloscope and electrical-phase traceability
- Instrument Maker adds electrical phase reference and asks for NIST traceability
- Instrument Maker announces 220 GHz VNA with no Coaxial Calibration Kit
 - Joint experiments to investigate direct NIST photodiode calibrations
 - Need 220 GHz calibration kits supporting on-wafer impedance-power-phase

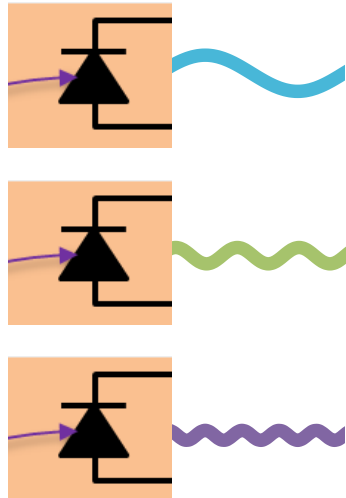
The Future of Vector Network Analyzers



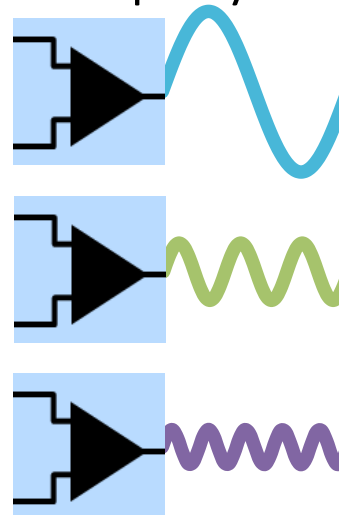
1. Control



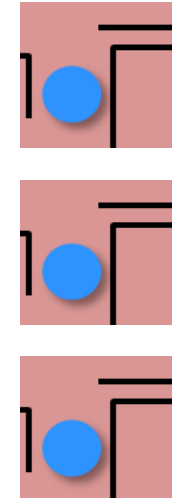
2. Convert



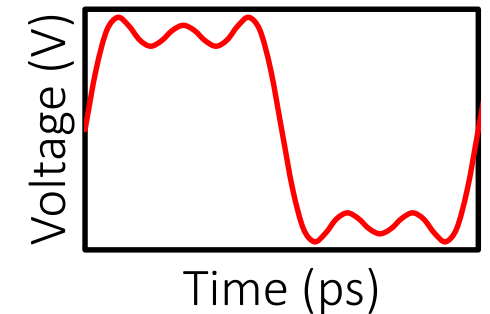
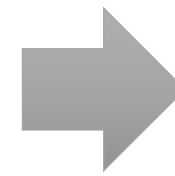
3.1 Amplify



3.2 Combine

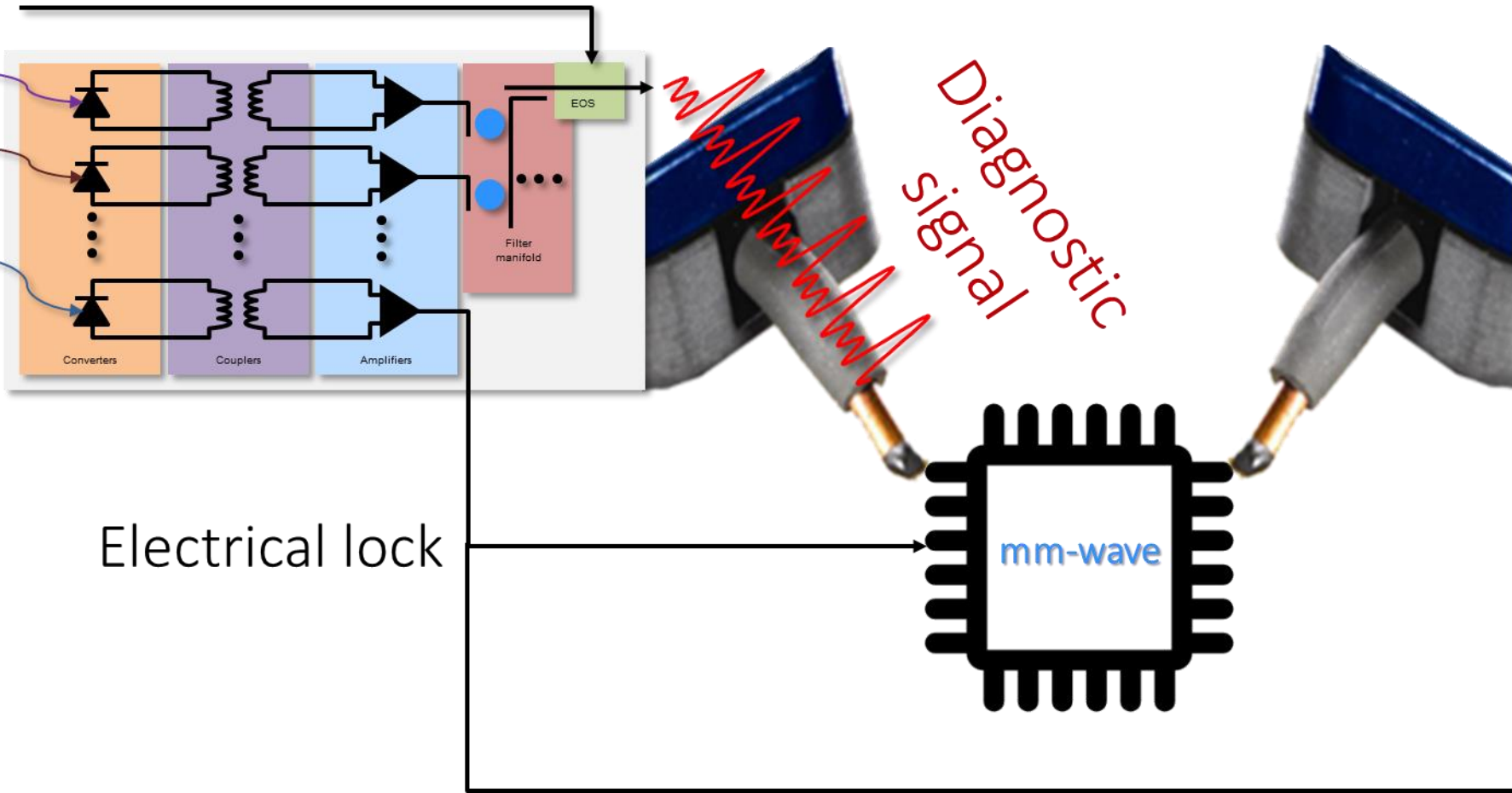


Diagnostic Signal

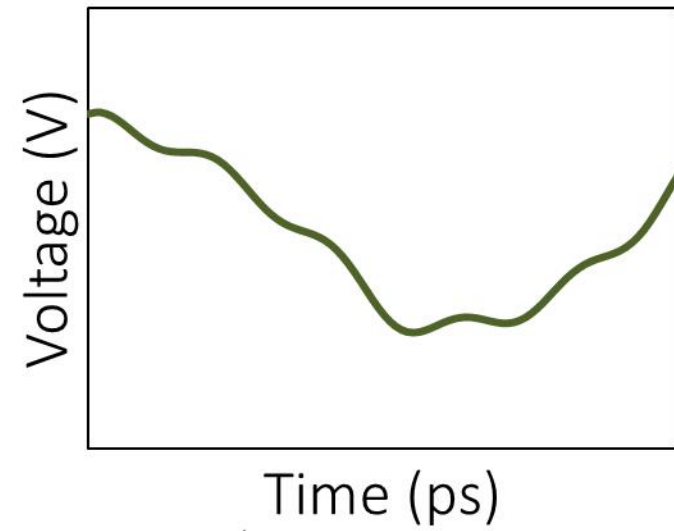


Everything in a Probe to Measure mmWave ICs

Electro-optic sampling

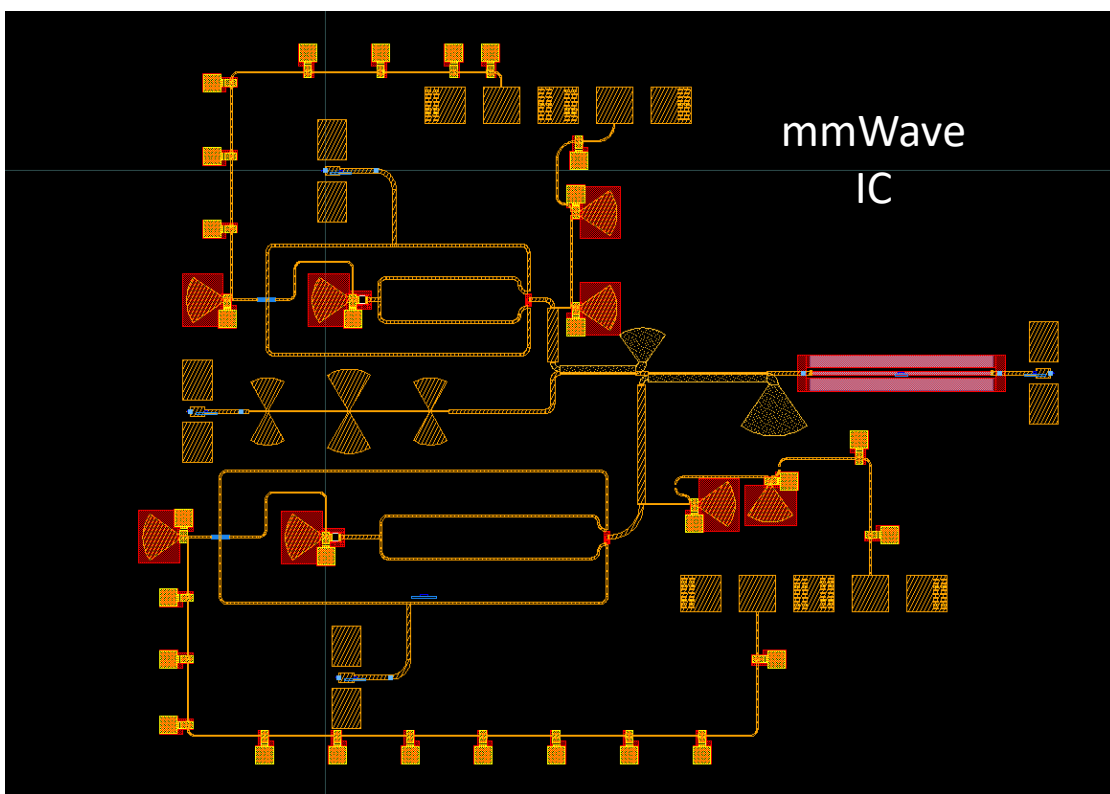


Output



Vector Network Analyzer in-a-Probe

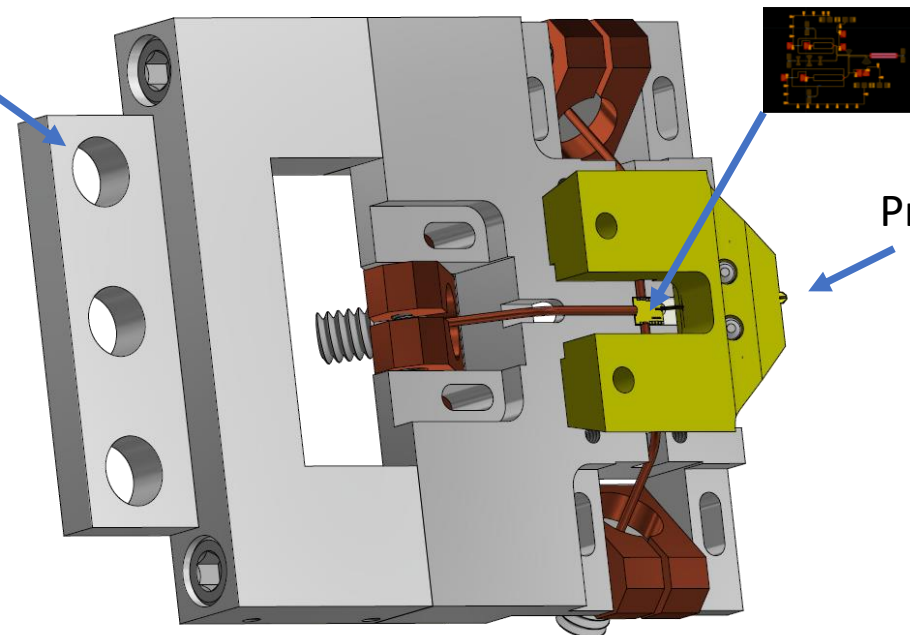
60 GHz – 270 GHz VNA-on-a-chip



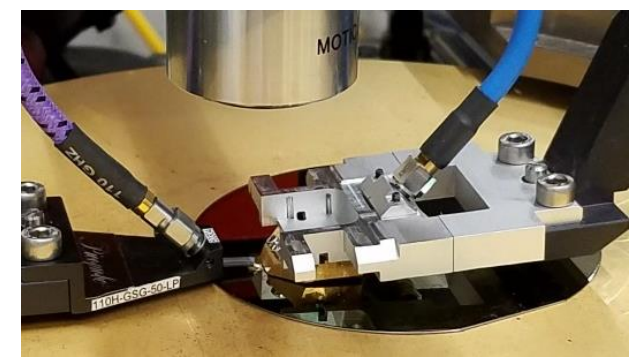
3 mm

60 GHz – 270 GHz VNA-in-a-probe

Probe-Station Mount

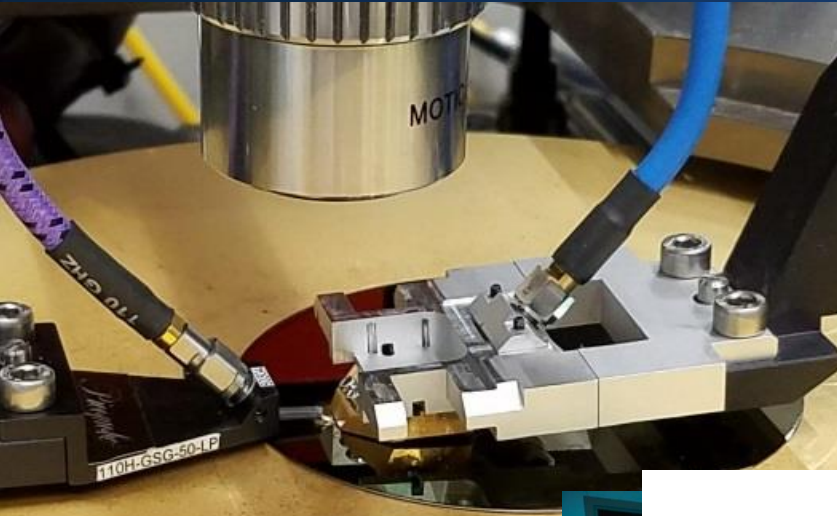


Probe Tip



CTL at Cutting Edge of On-Wafer-to-OTA Test

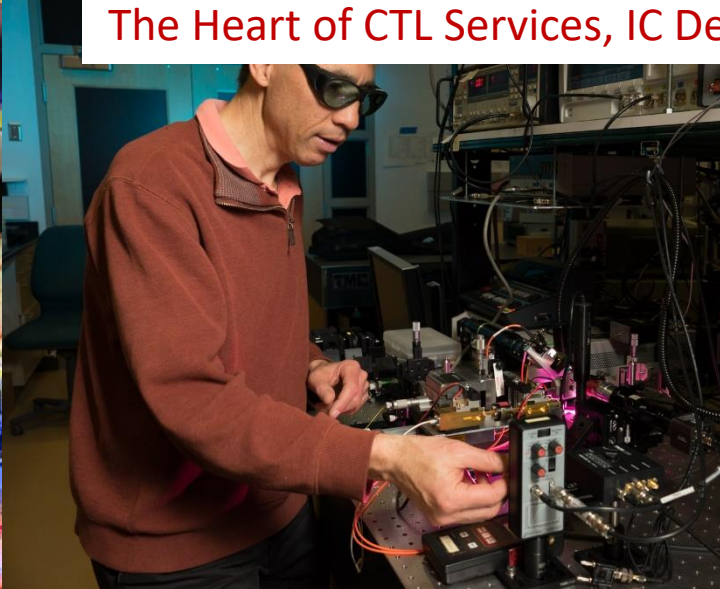
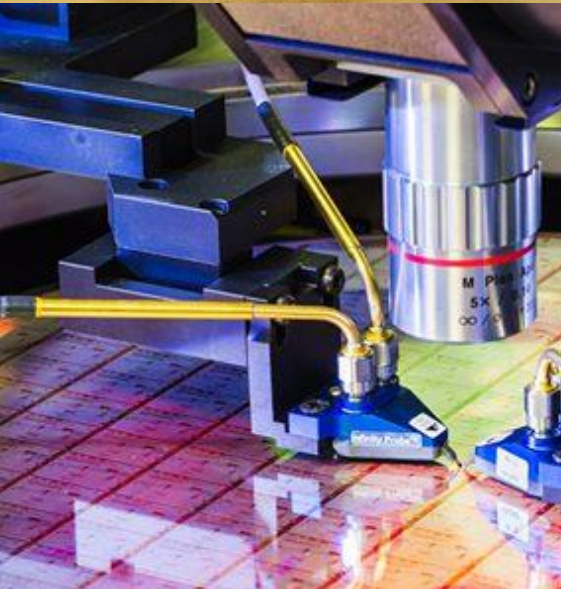
NIST



mmWaves are the Wireless Frontier



Vector Network Analysis
The Heart of CTL Services, IC Design and OTA System-Level Test



On-Wafer



System-Level Test



Free-Space